

Abstract

DNA is a promising candidate for nanoelectronics applications due to its customizable base sequence, low-cost replication, and self-assembly capabilities. While native DNA is a poor conductor and sensitive to environmental conditions, its conductivity and stability significantly improve when intercalated with metals, making it more robust and suitable for electronic integration.

Theory and Method

Density Functional Theory:

Used to calculate ground state energy (E) and Hamiltonian (H<sub>0</sub>)

Transport

$T_{mn} = \Gamma_m G^r \Gamma_n (G^r)^\dagger$ , where  
 $G^r = [EI - (H_0 + \Sigma_L + \Sigma_R + \Sigma_B)]^{-1}$  and  $\Gamma_i(E) = -2Im(\Sigma_i)$

Here  $G^r$  is the retarded Green's function and  $\Sigma_{L/R}$ ,  $\Sigma_B$  are the self energy of left/right contacts and Buttiker probes respectively.

DNA as a device

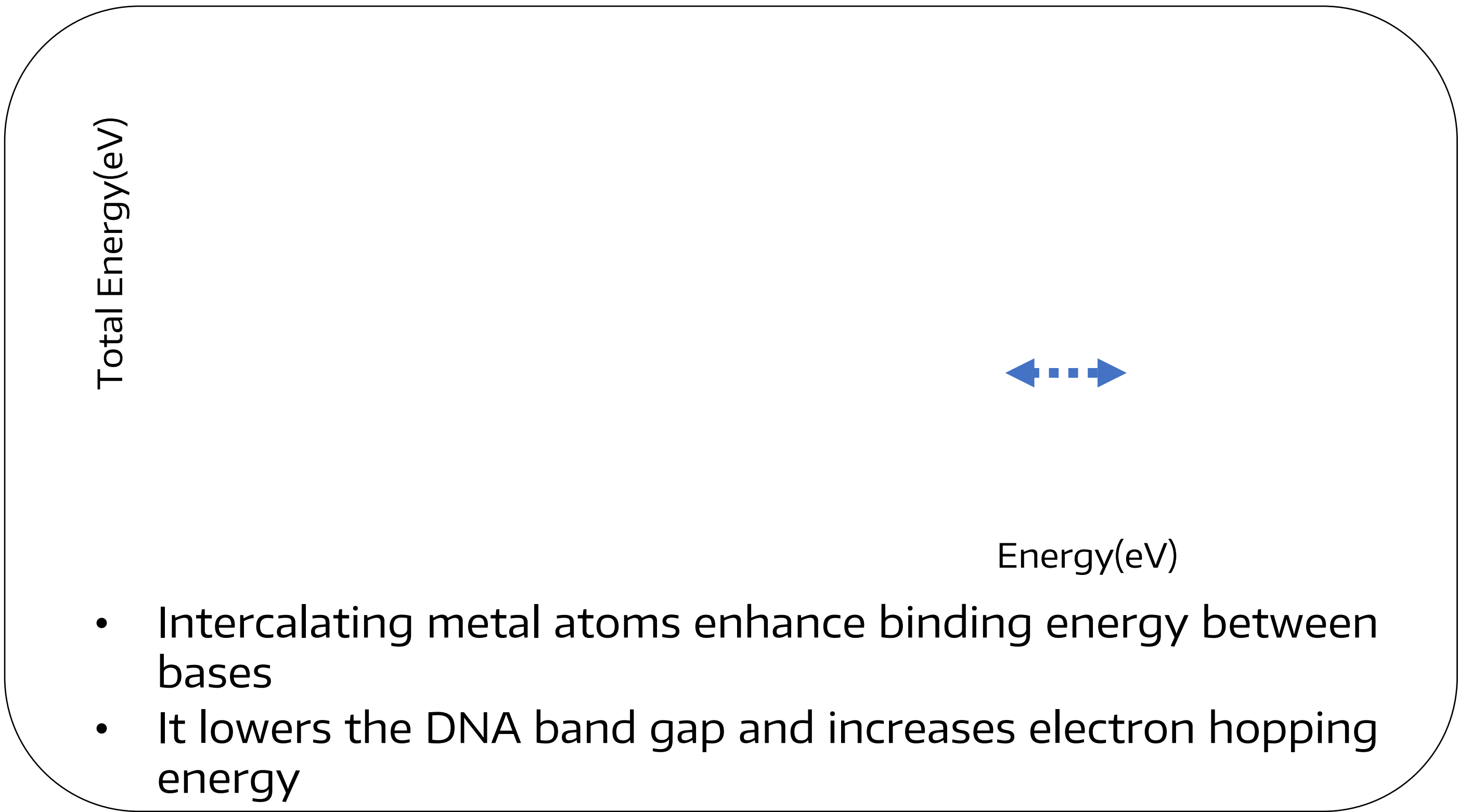
- Electrical devices are an engineered arrangement of energy levels.
- DNA offers stability, adjustable energy levels, self-organization, and programmability.

Challenges

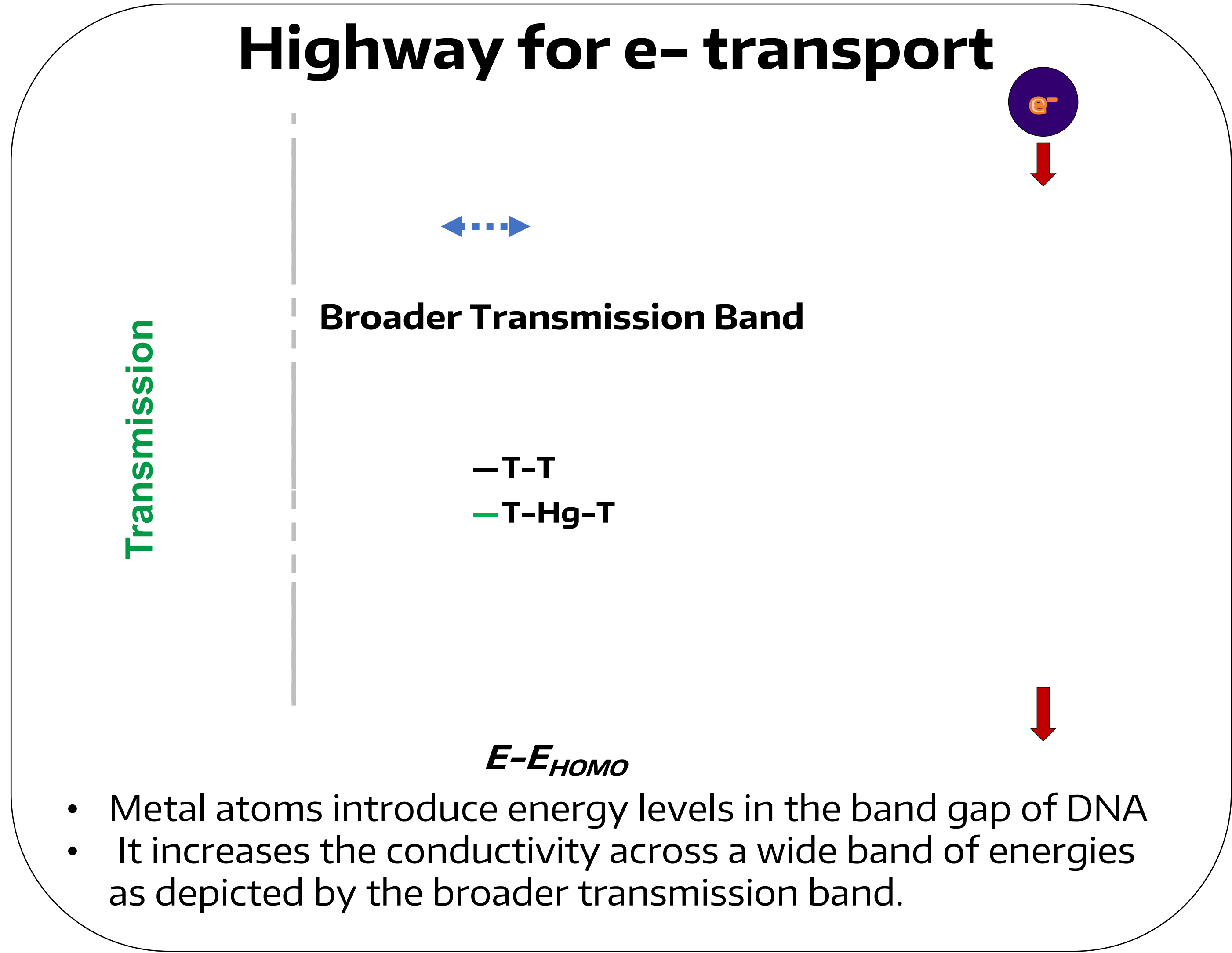
- Binding energies between bases ~ 100-130 meV in their native form
- Low electron hopping integral (10-100 meV)

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Metal Intercalated Base Pairs



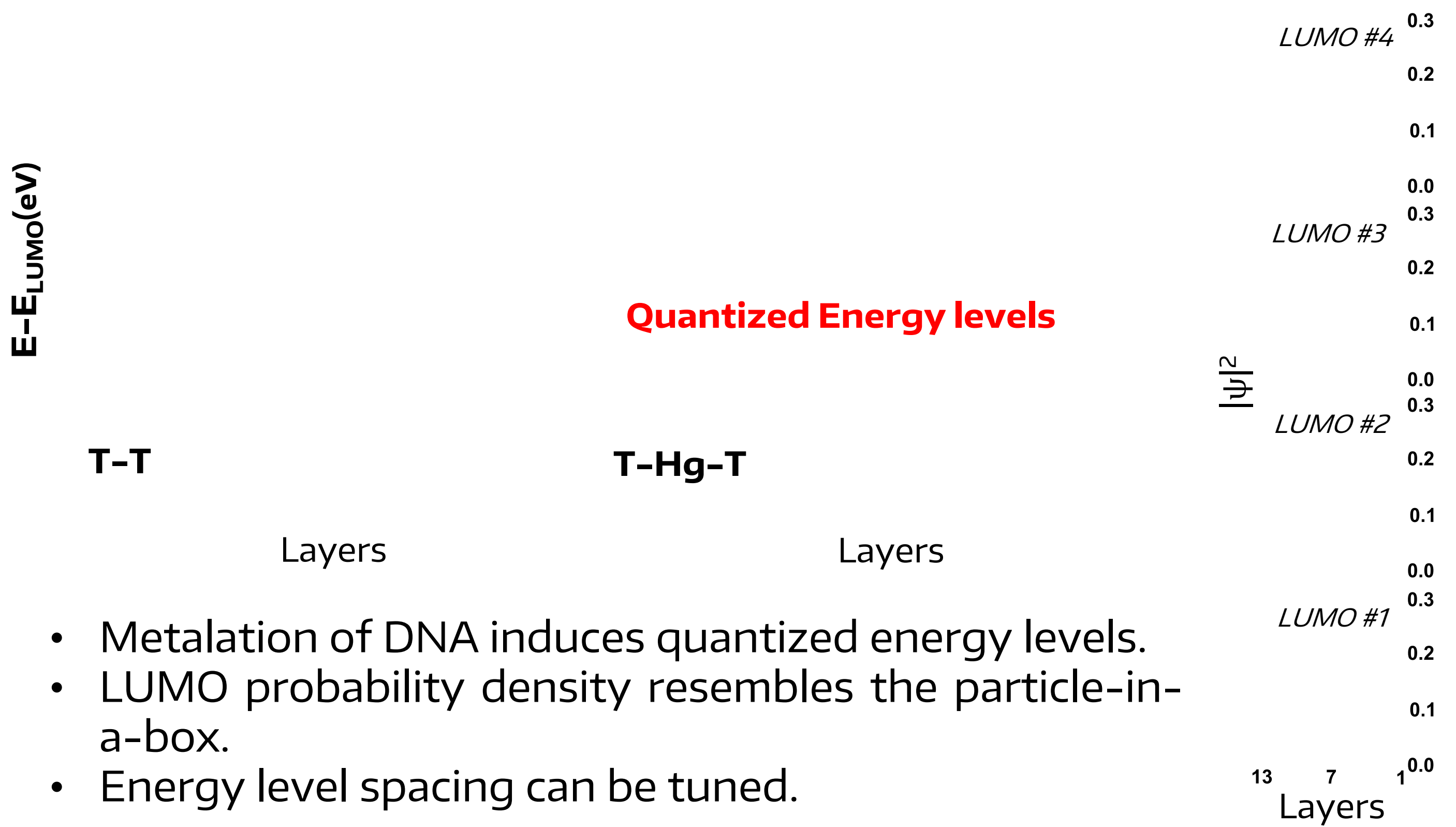
Highway for e- transport



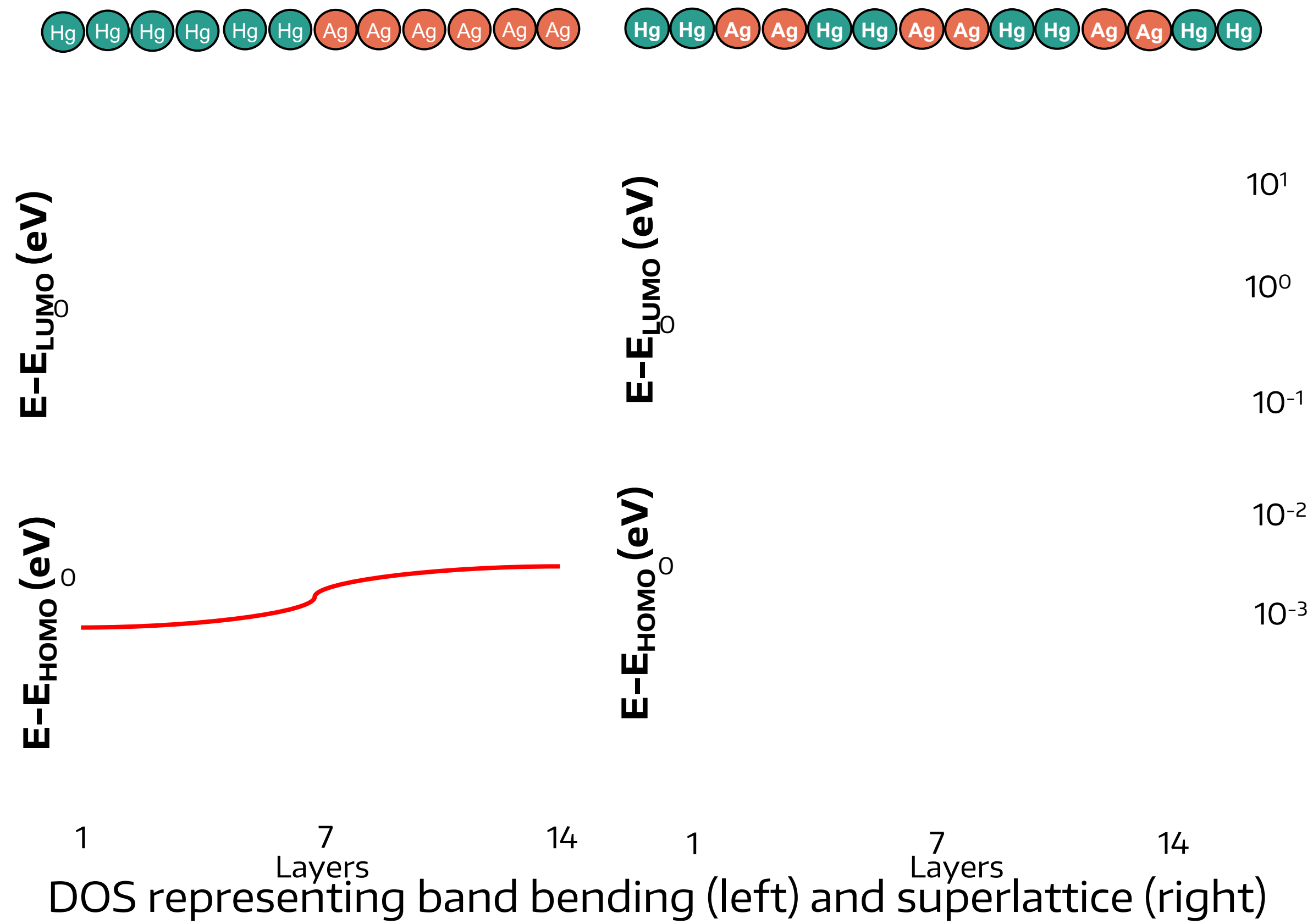
References

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Vecchioni, Simon et al., doi:10.1002/adma.202210938  
J. Kondo et al., doi: https://doi.org/10.1038/nchem.2808.

Energy Quantization



Band Bending and Superlattices



Conclusion

- Metal intercalation enhances the conductivity and stability of DNA nanowires.
- *Strong* transmission path is possible at the LUMO of T-Hg-T
- Electronic properties can be tailored: superlattices and band bending.
- It presents an engineered nanomaterial to probe molecular scale band engineering